

Erratum to: Enhanced phonon transmission at thin-film Si on diamond interface via microtransfer printing

Yang He¹, Shun Wan², Yinfei Xie¹, Shi Zhou², Xiaonan Wang¹, Weiye Liu¹, Yongwei Chang³✉, Yan Zhou²✉, Lifa Zhang²✉, and Huarui Sun^{1,4}✉

¹School of Science and Ministry of Industry and Information Technology Key Laboratory of Micro-Nano Optoelectronic Information System, Harbin Institute of Technology, Shenzhen 518055, China

²Phonon Engineering Research Center of Jiangsu Province, Institute of Physics Frontiers and Interdisciplinary Sciences, School of Physics and Technology, Nanjing Normal University, Nanjing 210023, China

³State Key Laboratory of Materials for Integrated Circuits, Shanghai Institute of Microsystem and Information Technology, Chinese Academy of Sciences, Shanghai 200050, China

⁴Collaborative Innovation Center of Extreme Optics, Shanxi University, Taiyuan 030006, China



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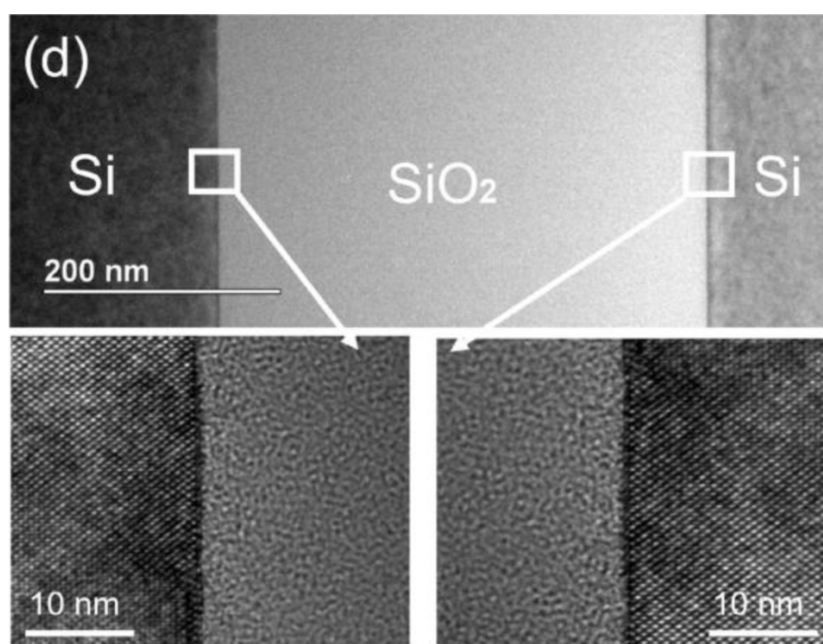
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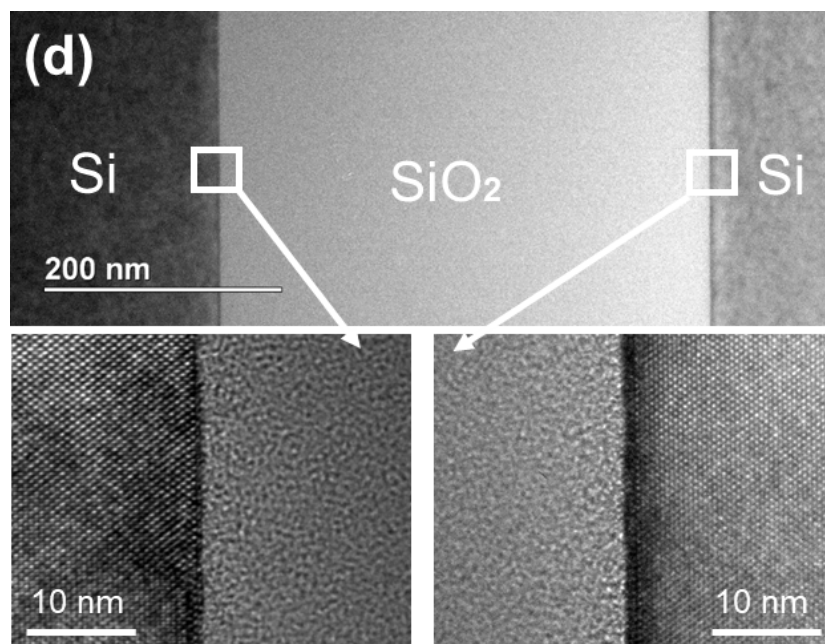
The article *Enhanced phonon transmission at thin-film Si on diamond interface via microtransfer printing*, written by Yang He et al., was erroneously originally published with Fig. 2(d).

Instead of



✉ Address correspondence to Huarui Sun, huarui.sun@hit.edu.cn; Yan Zhou, yan.zhou@nnu.edu.cn; Lifa Zhang, phyzlf@njnu.edu.cn; Yongwei Chang, ywchang@mail.sim.ac.cn

It should read



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